

Standoff Detection of Chemical Residues using Quantum Cascade Lasers

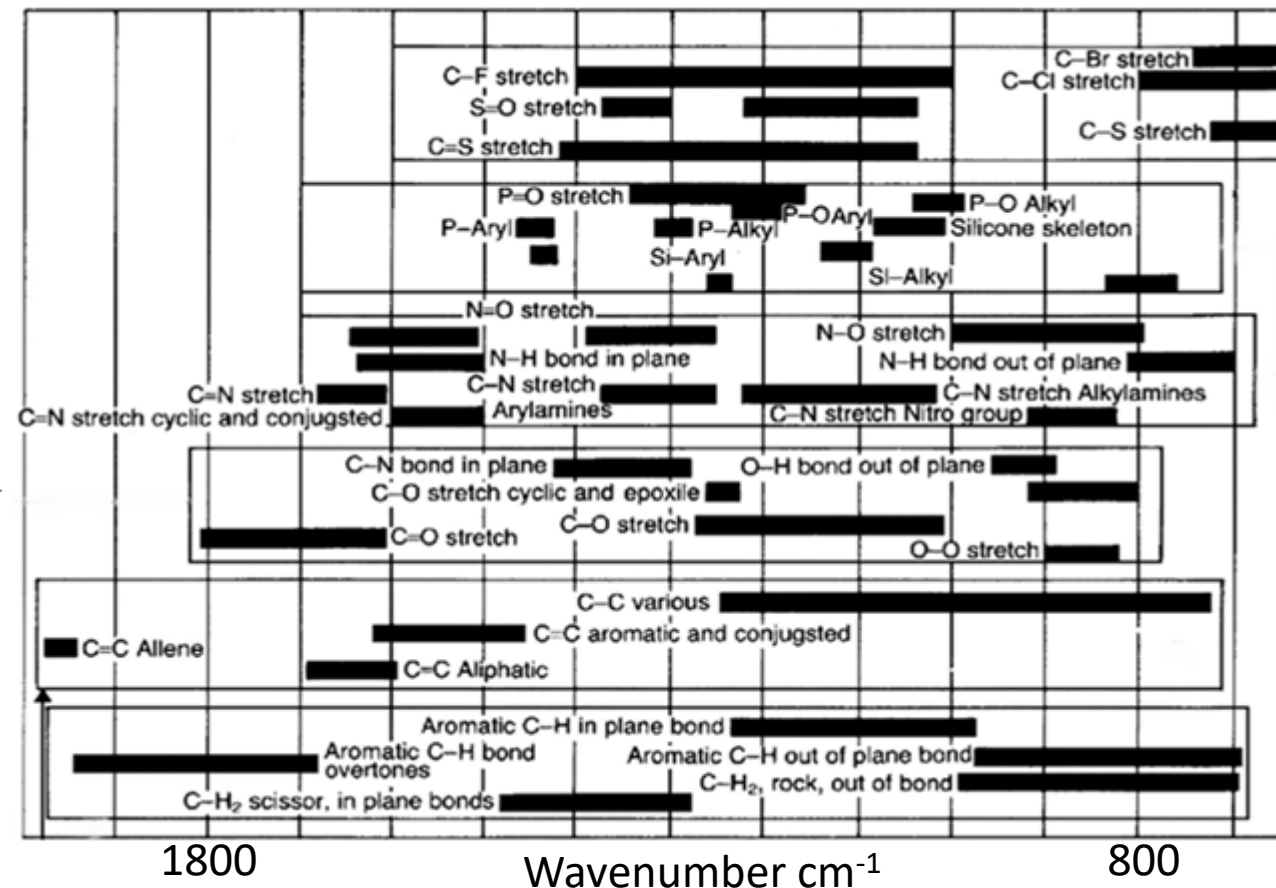
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Metrology Research Center

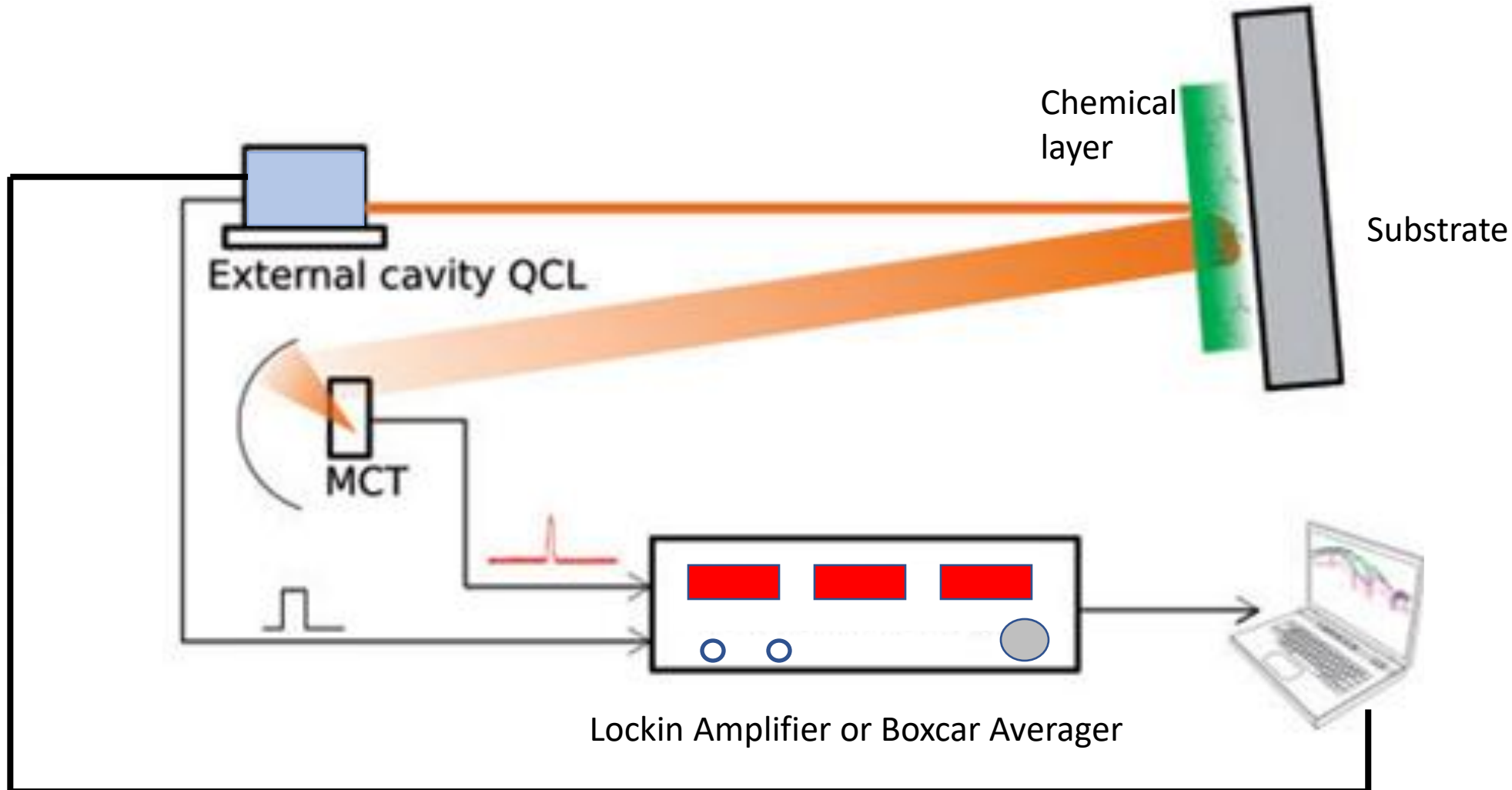
National Research Council of Canada

Ottawa, Ontario K1A 0R6

- Coverage of the fingerprint range →
- QCLs are bright, collimated, wavelength tunable
- Standoff demo with our lasers

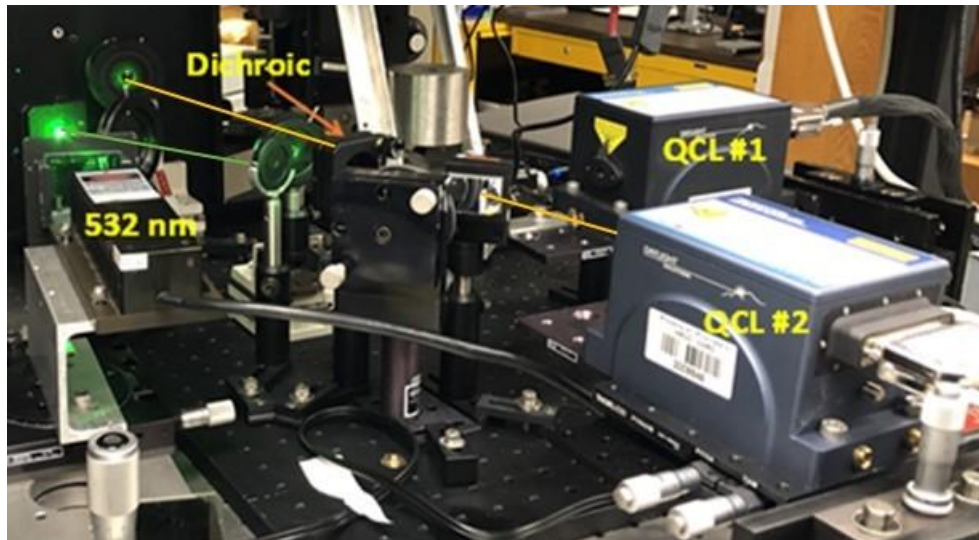


Standoff detection of chemical residues using quantum cascade lasers

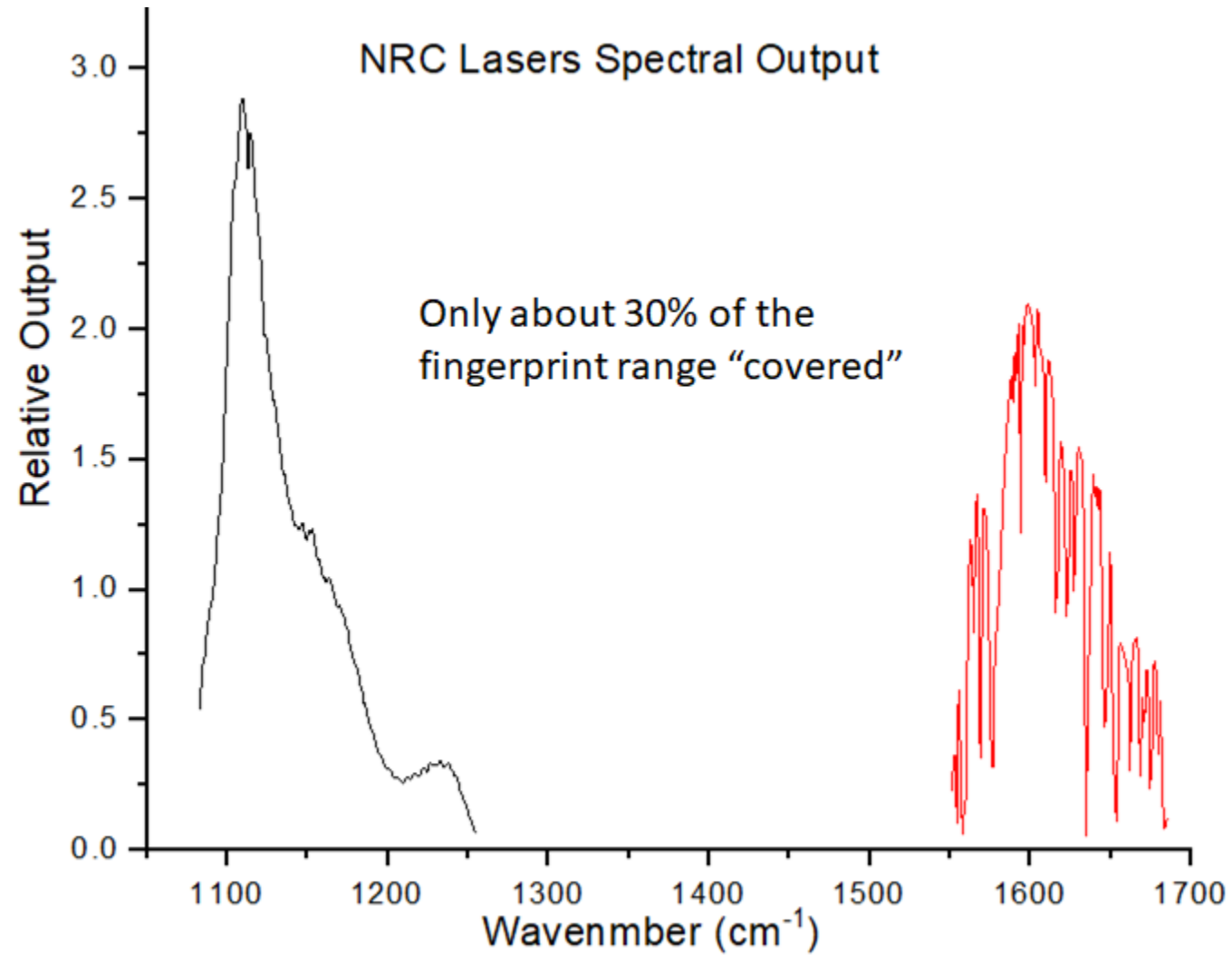


Quantum Cascade Lasers – Spectra

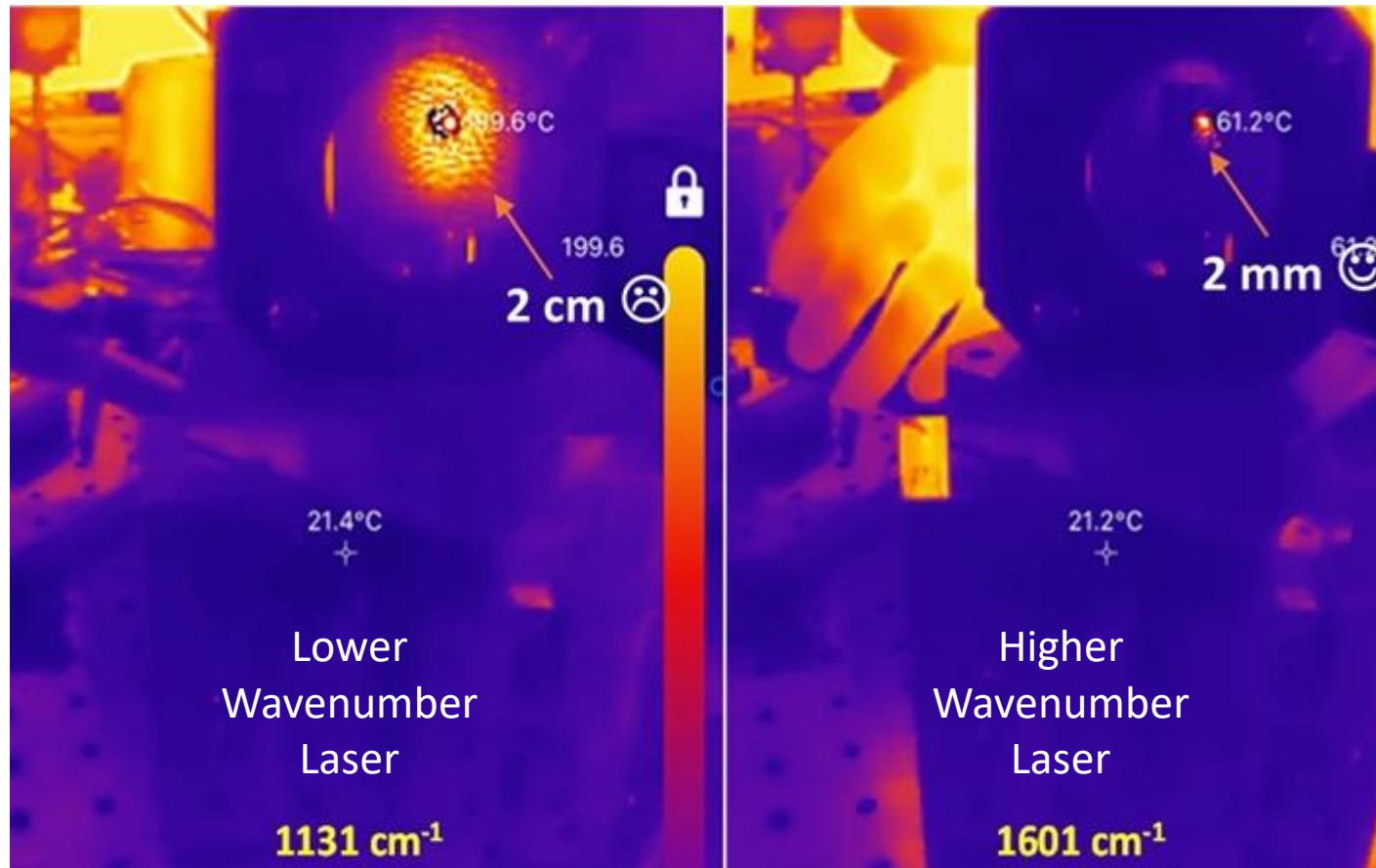
The Daylight Solutions QCLs



For alignment, the QCLs have a common path with a 532 nm laser

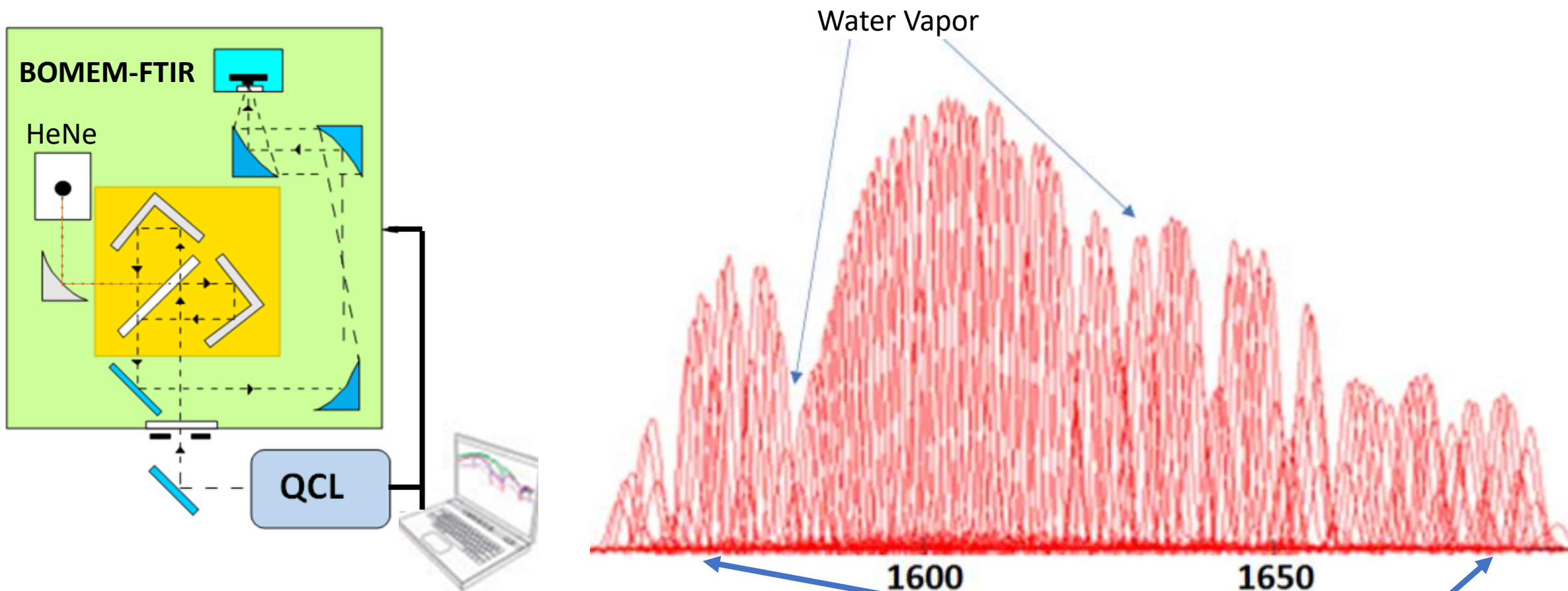


QCL Characteristics: Beam size, Collimation



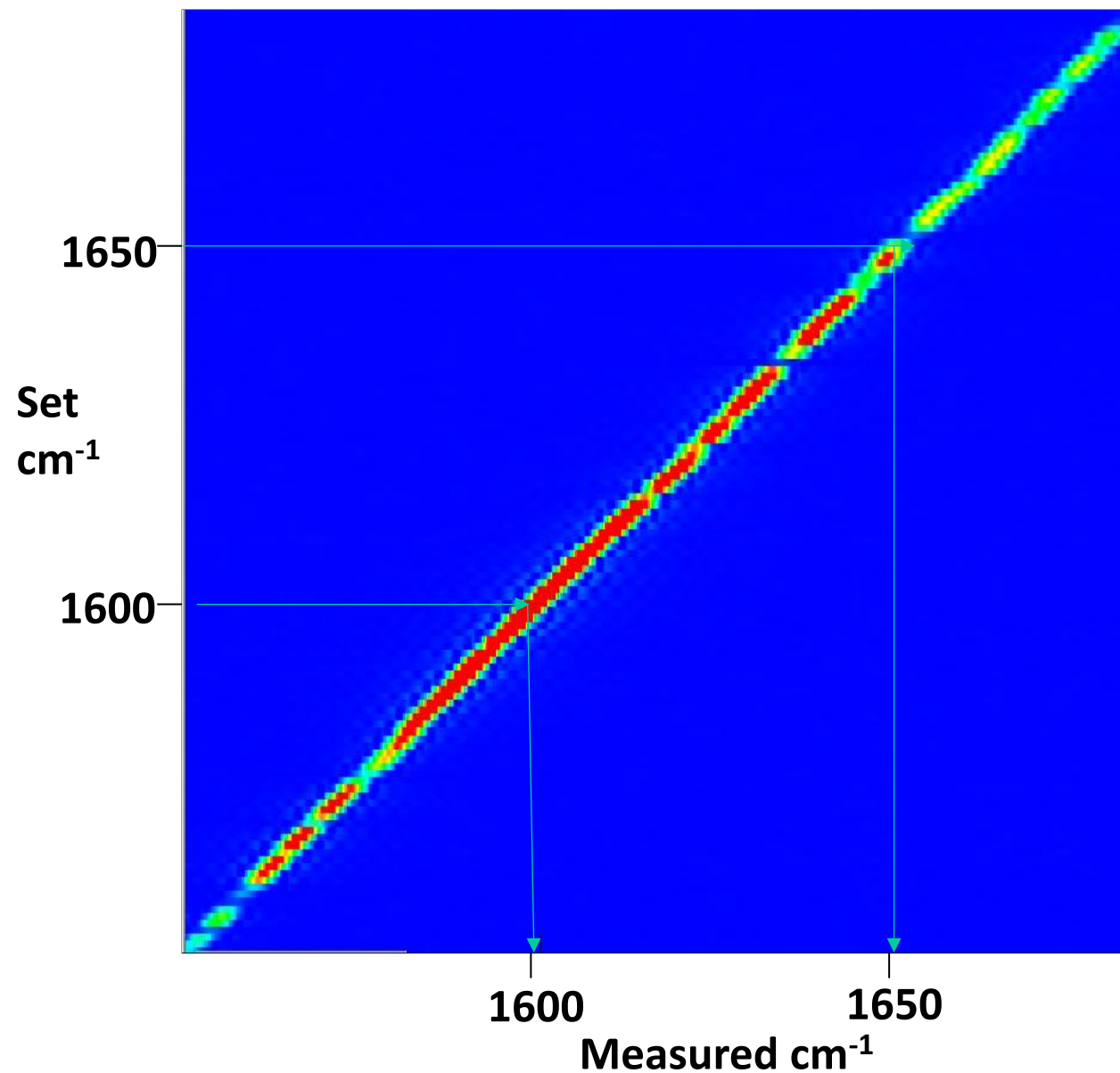
Thermal images ~ 1 meter from the lasers

Measuring QCL Spectrum: Wavenumber Calibration 1550 – 1685 cm^{-1}

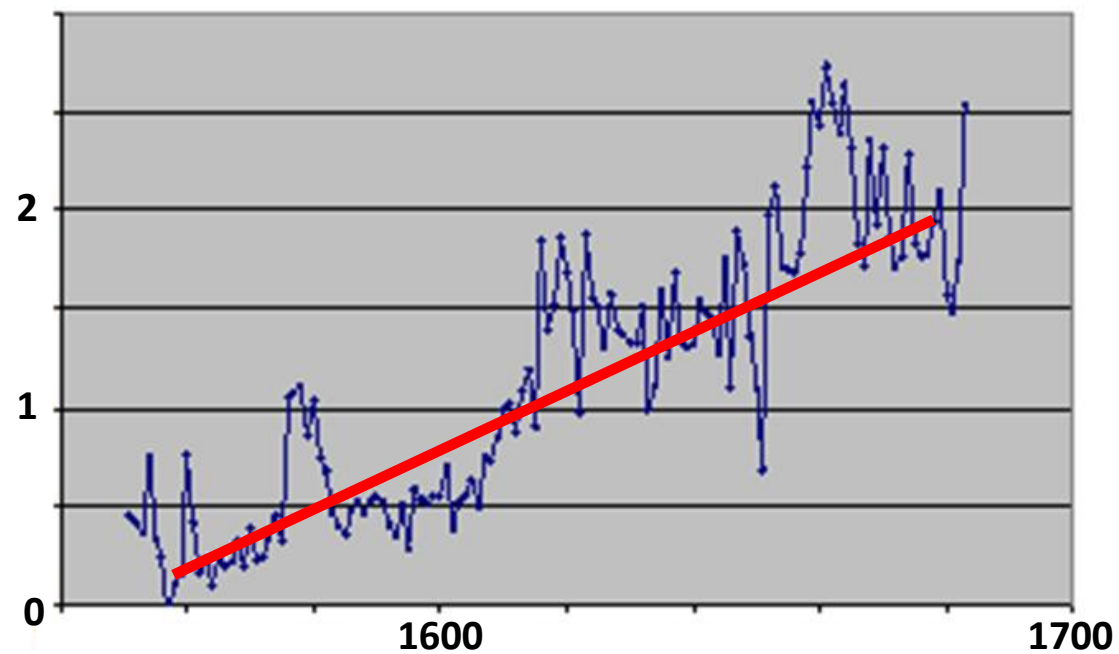


Bomem MB FTIR as a wavemeter using its external port. Spectra every 1 cm^{-1}
 Measurement Program: step QCL cm^{-1} , save interferogram/HeNe fringes, repeat
 next step ($+1 \text{ cm}^{-1}$), analyze interferogram files into spectra

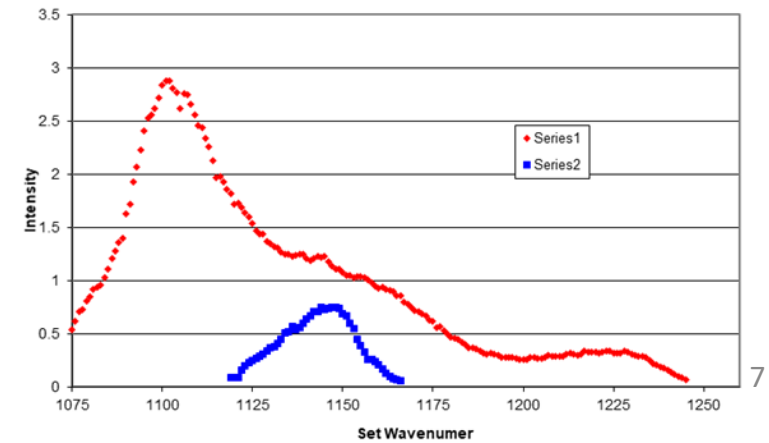
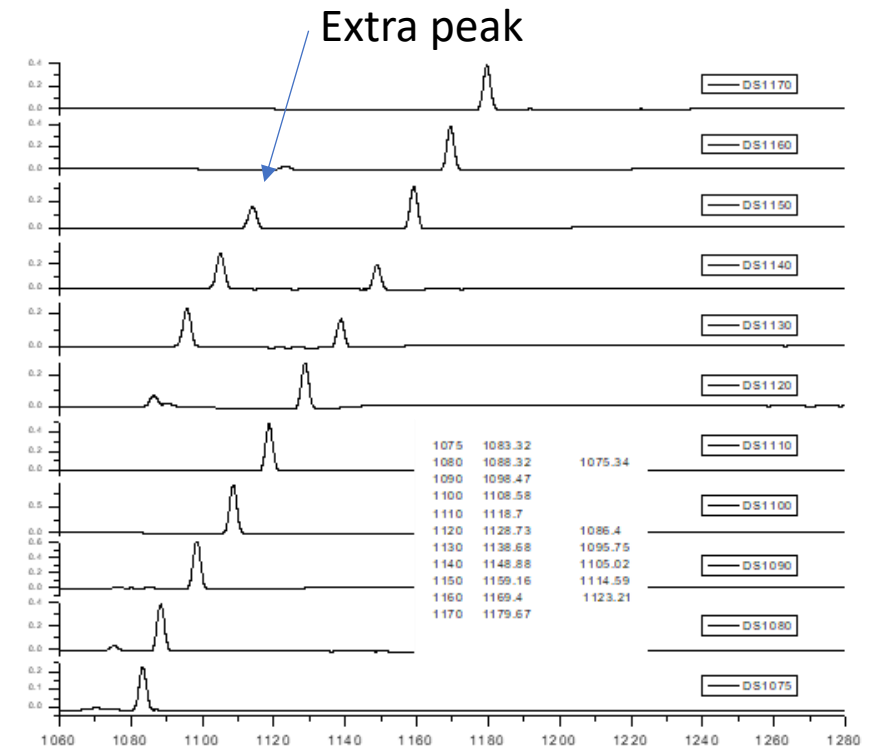
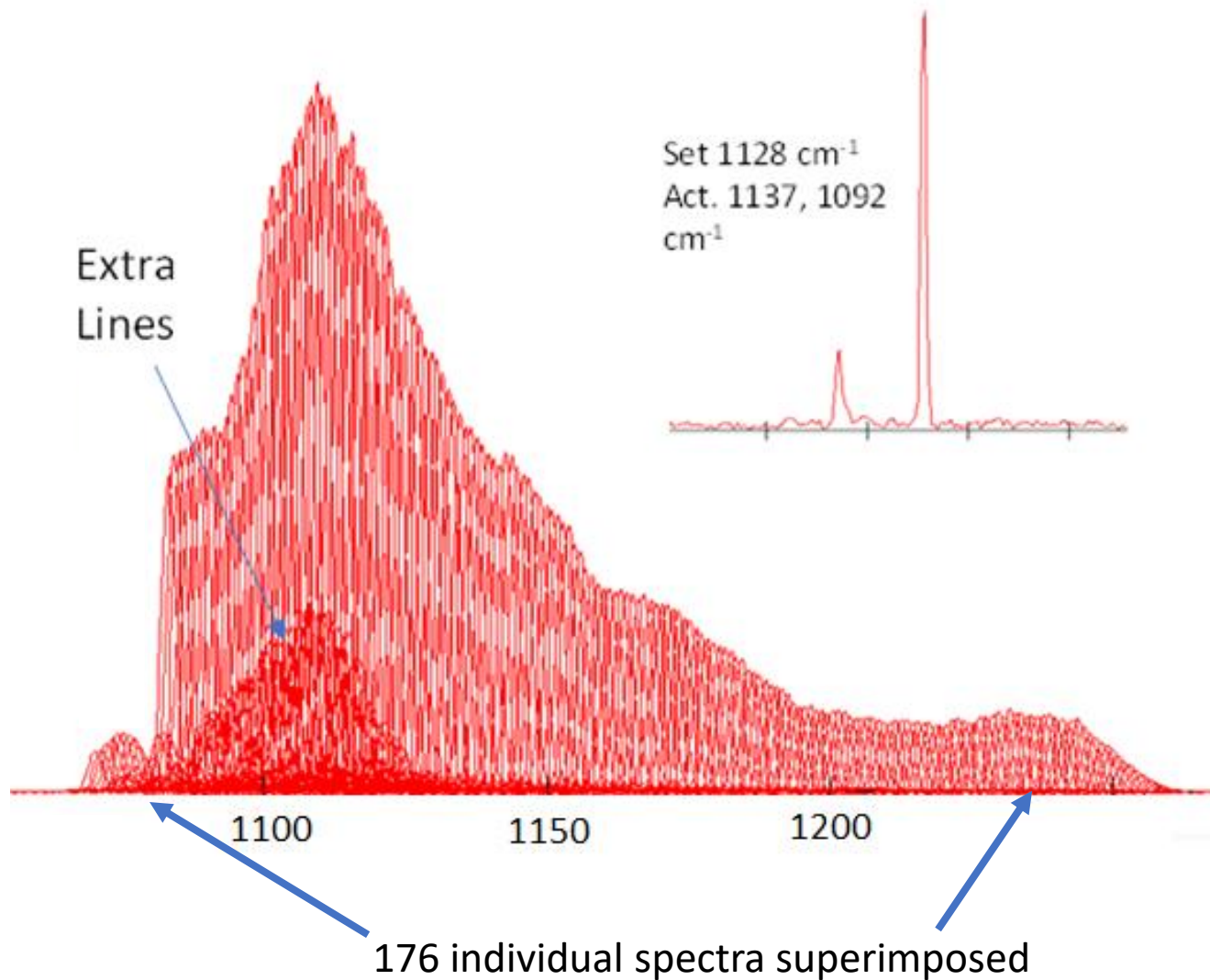
For spectroscopy: need the actual wavenumber value for a given setting



Measured - Set Wavenumber



QCL Spectrum? Wavenumber Calibration 1075 – 1250 cm^{-1}

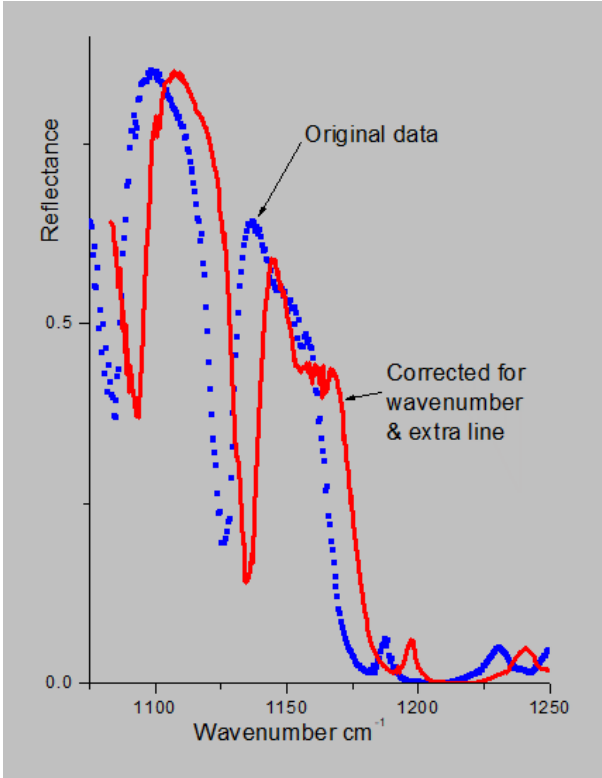
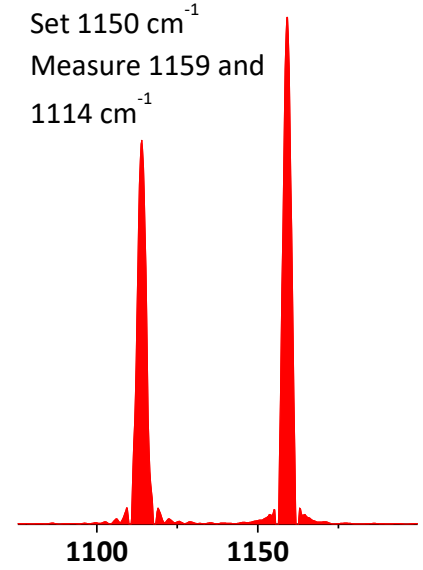
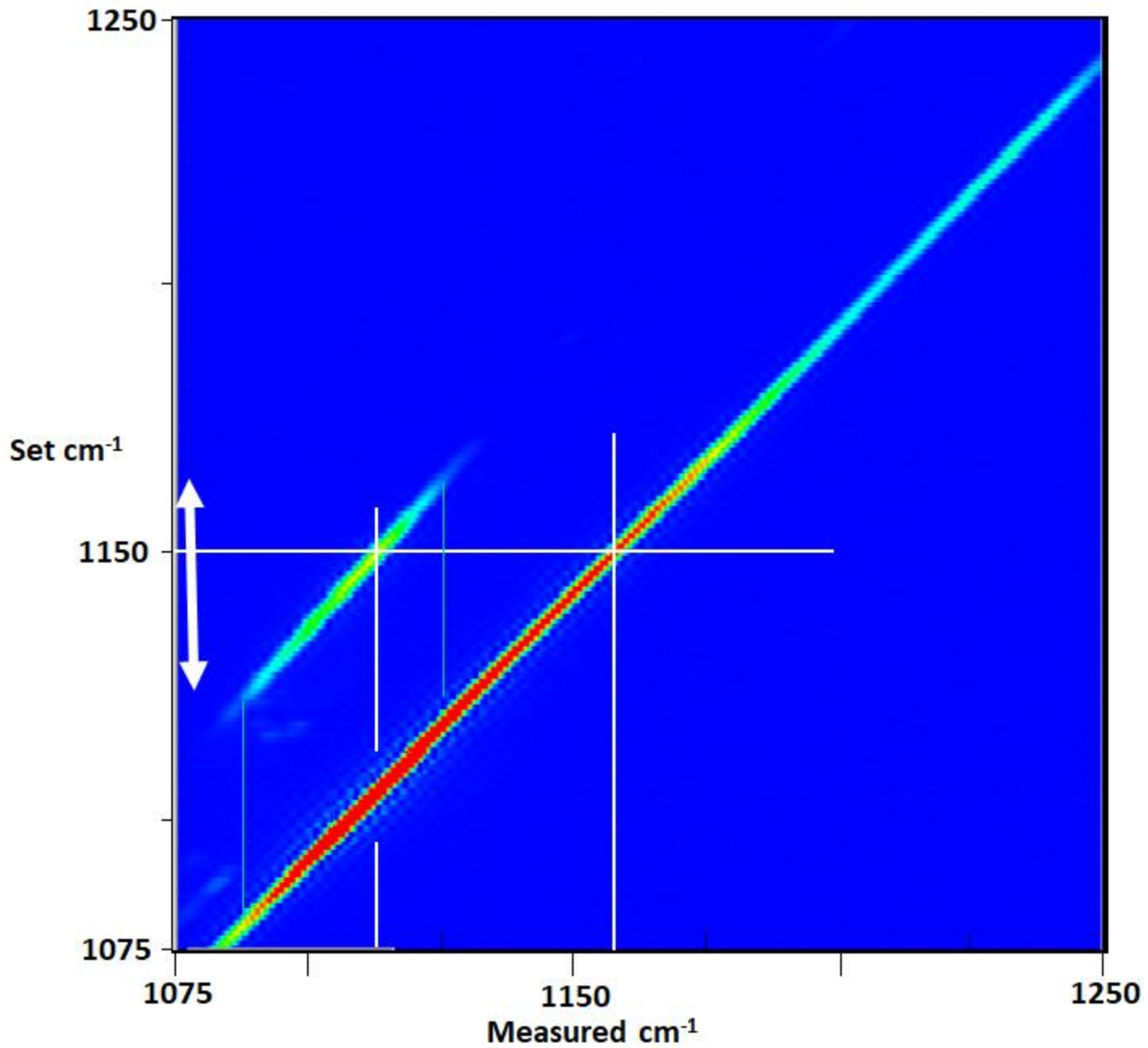


Laser

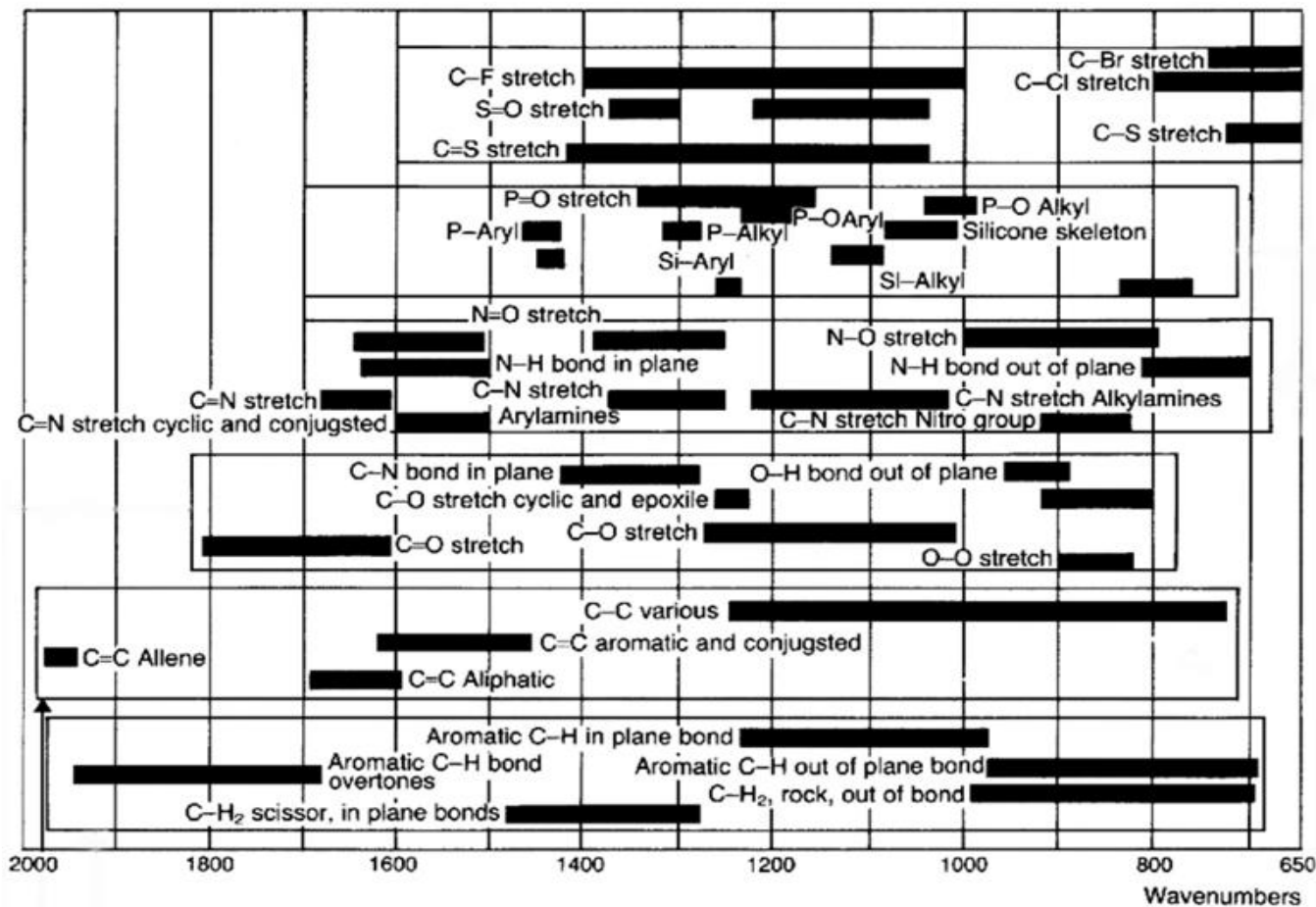
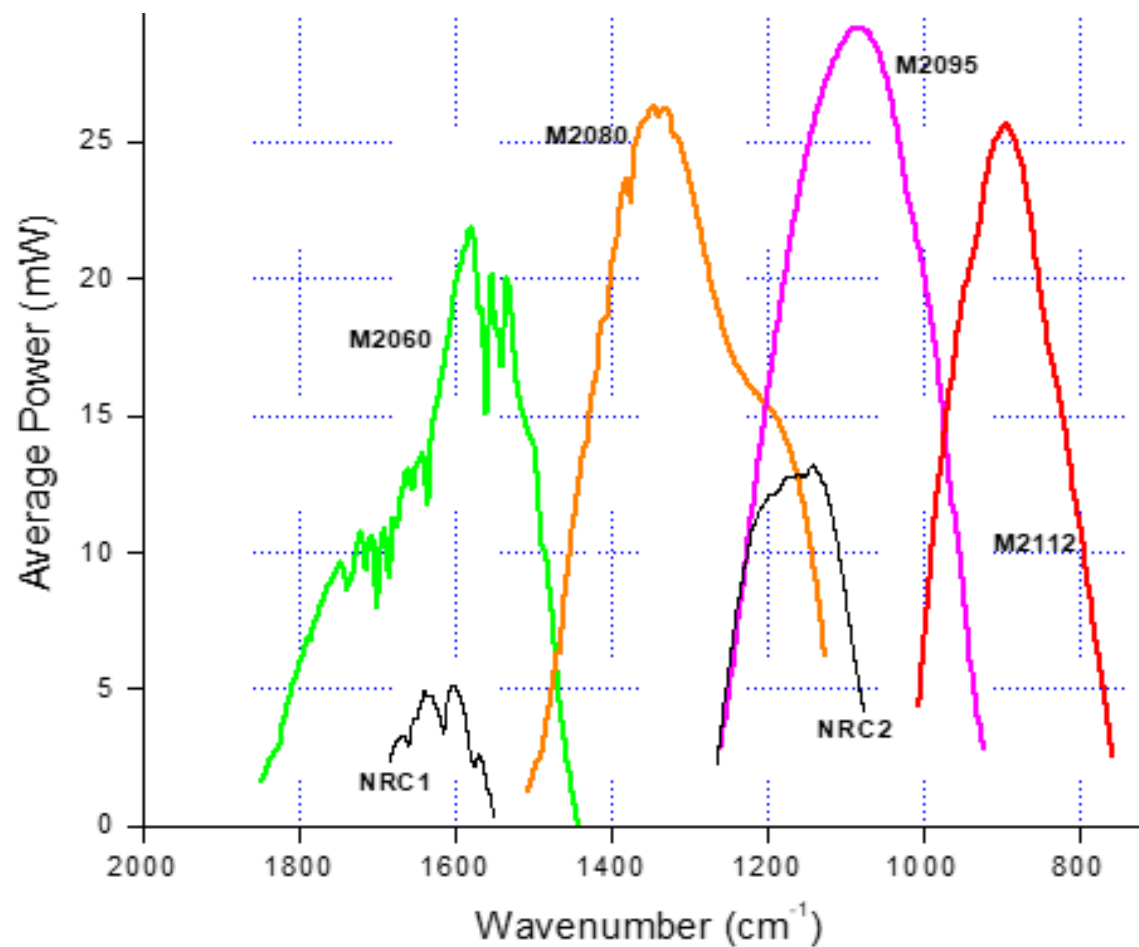
Performance

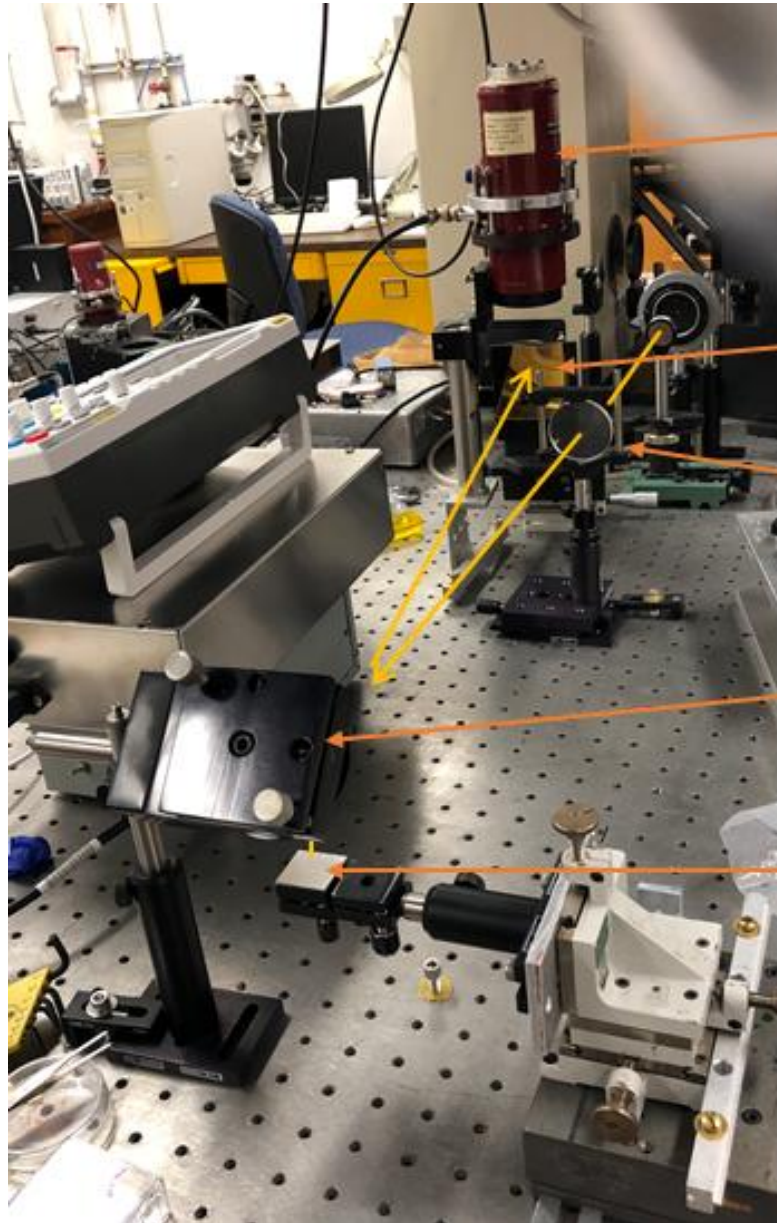
- Source based spectroscopy
- Wavenumber linearity
- Uniqueness

- Wavenumber offset
- For settings 1125 to 1160 cm^{-1} : two lines
- Correction algorithm
- Lower wavenumber (by 45 cm^{-1}) line thwarted



Performance Improvements DLS QCLs – Tuning Range and the Fingerprint Range





MCT detector
down looking

Parabolic
collection mirror

Laser lens
NaCl

Folding
Mirror

Sample
Coupon

Table Top Standoff Detection System

Distance – laser optics to sample 0.5 m

Distance – sample to collection optics 0.55 m

Reflectance angle – 4 degrees off normal

Quantum cascade lasers (QCLs) are the source

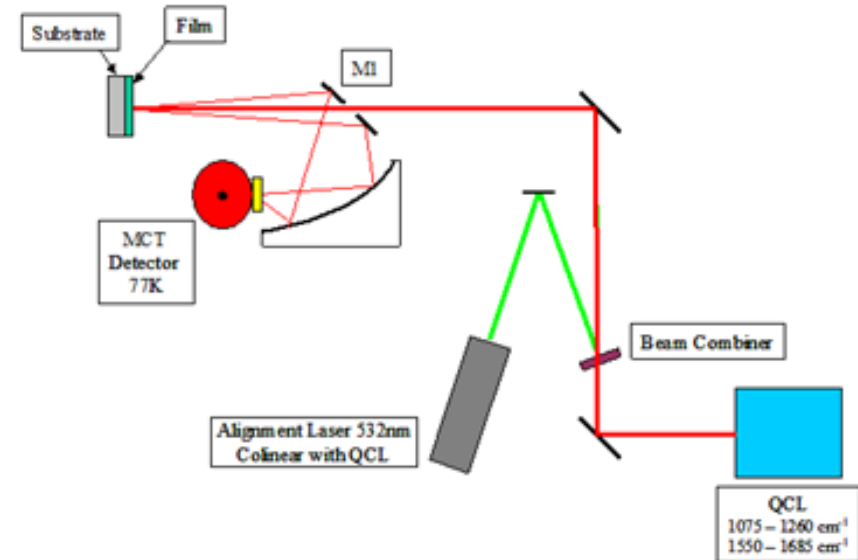
Spot size on sample ~ 2 mm diameter

QCL #1: 1075 to 1250 cm^{-1} (9.3 to 8 μm)

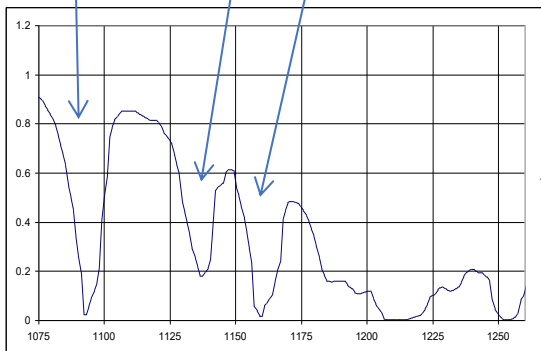
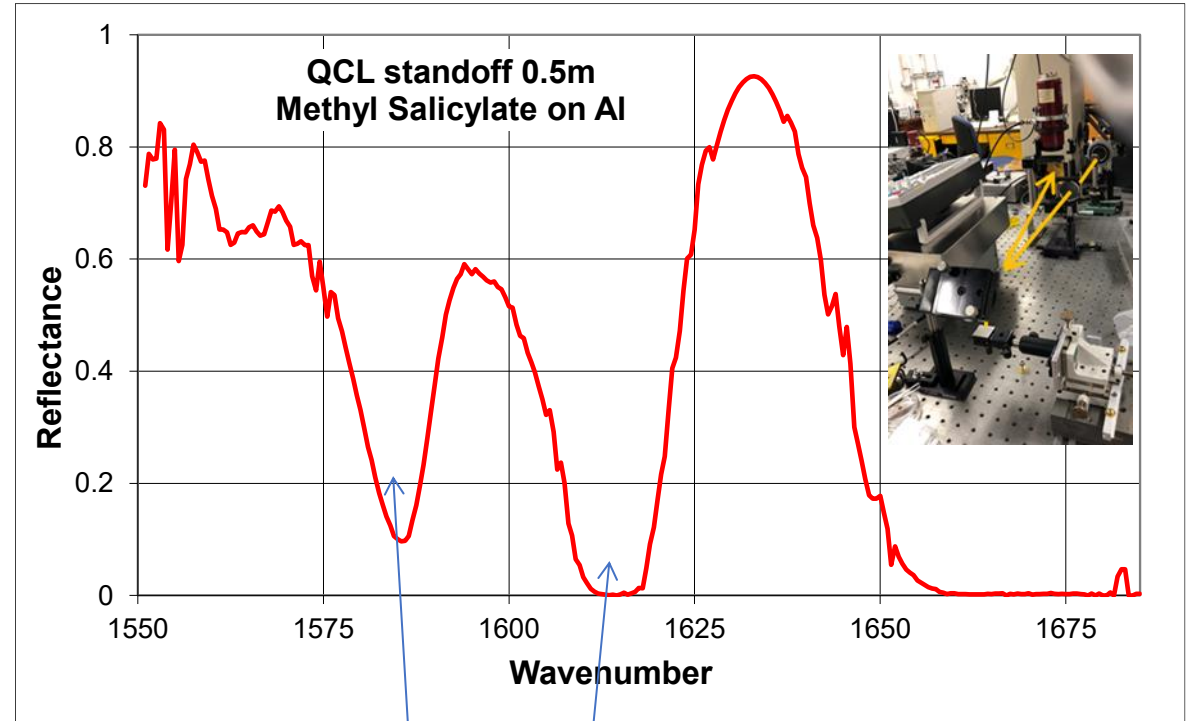
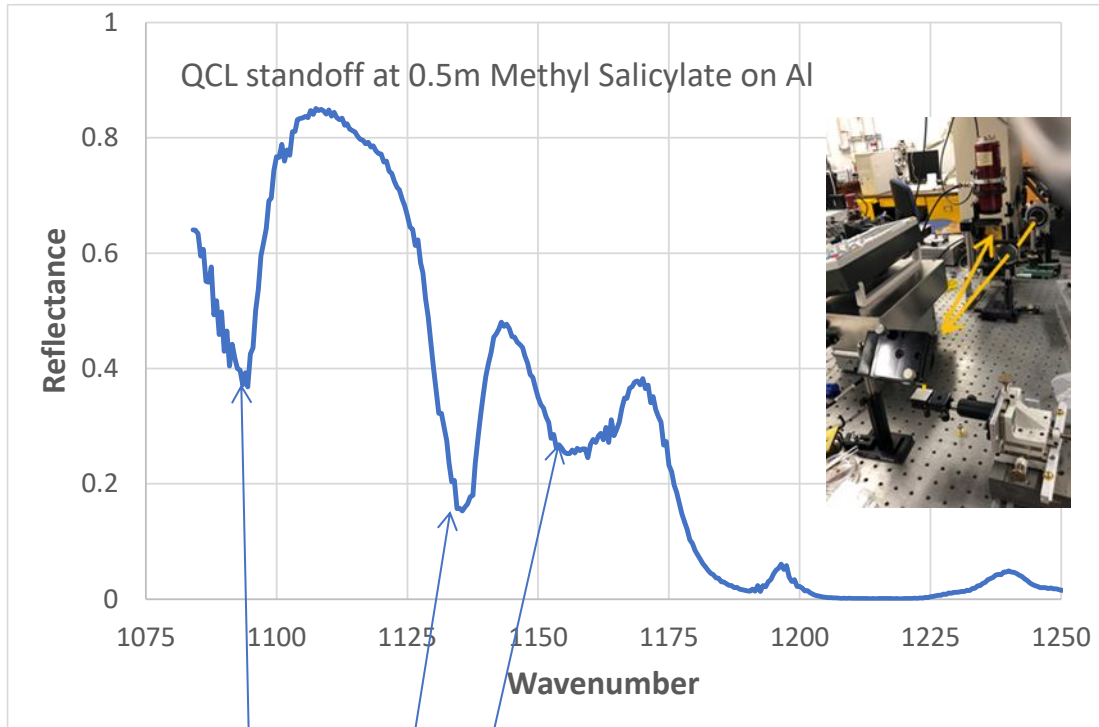
QCL #2: 1550 to 1685 cm^{-1} (6.45 to 5.93 μm)

Detector mercury cadmium telluride
photoconductor (77K)

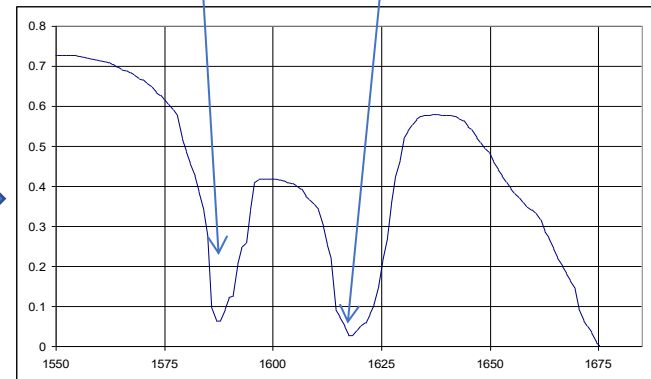
Spectra obtained by step scanning the lasers



Methyl Salicylate Liquid on Aluminum: Standoff at 0.5 m ~14 μm

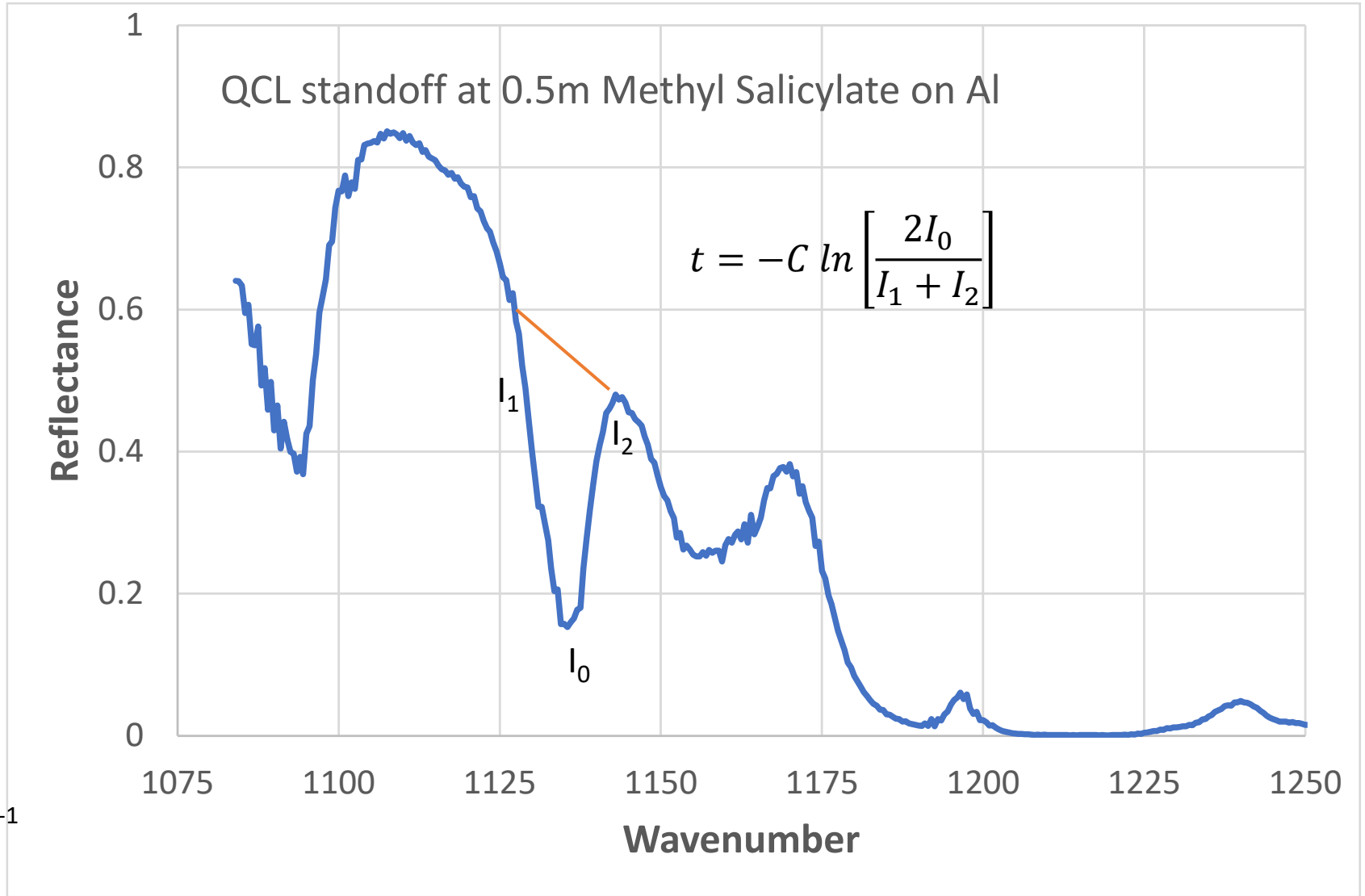
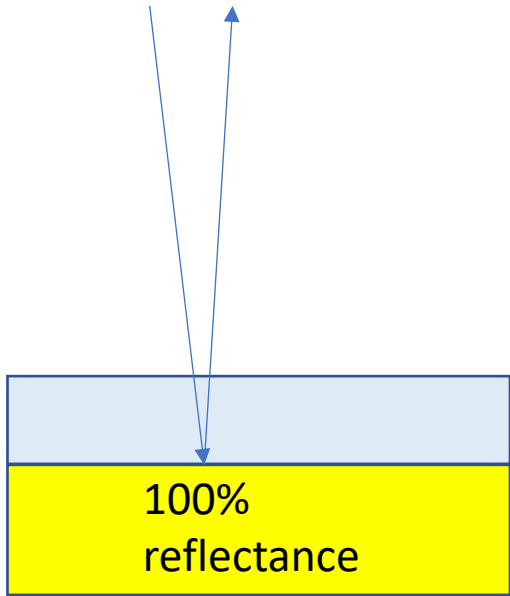


NIST Database Transmittance Spectra for 100 μm Methyl Salicylate



TAKEAWAY
Reasonable identification of the chemical. S/N implies sensitivity to much thinner films possible.

Methyl Salicylate Thickness estimation



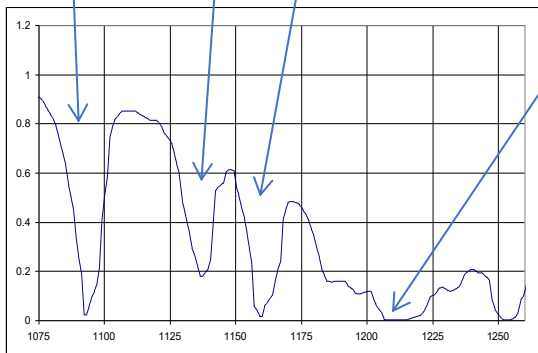
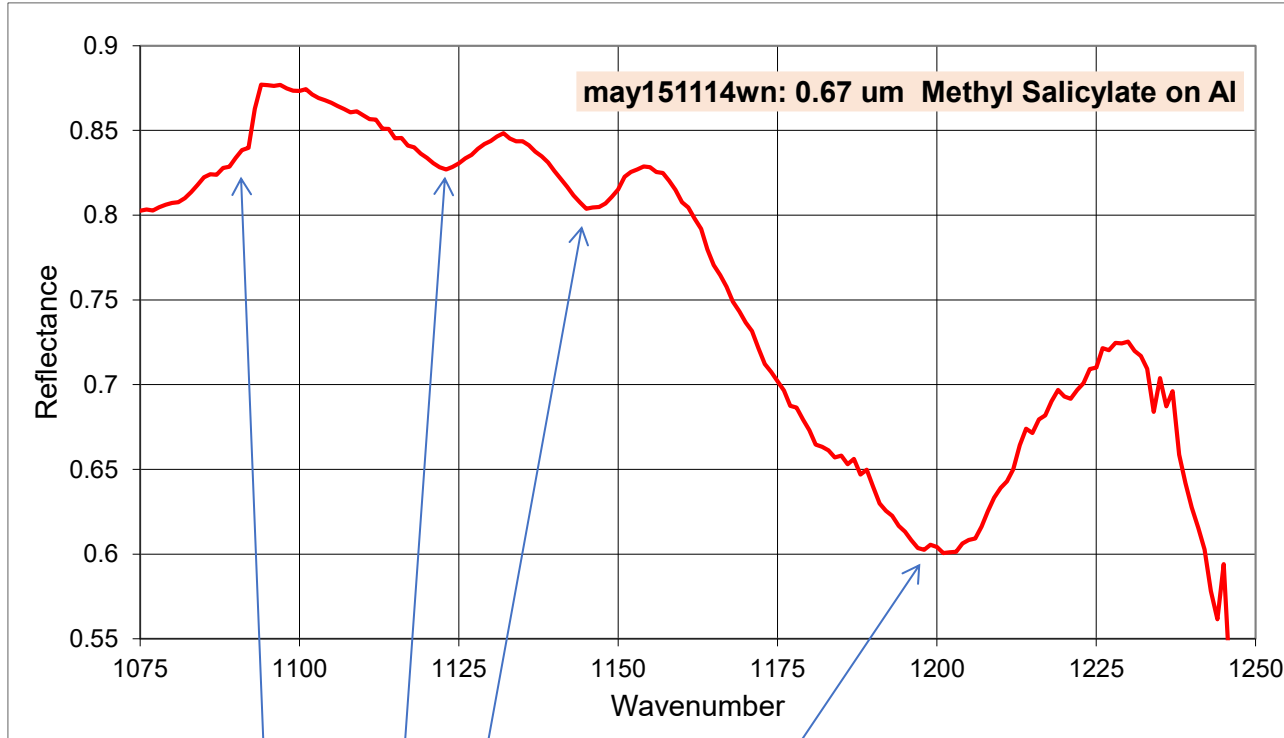
$$t = -13.9 \ln \left[\frac{2I_0}{I_1 + I_2} \right] \text{ at } 1087 \text{ cm}^{-1}$$

$$t = -38.1 \ln \left[\frac{2I_0}{I_1 + I_2} \right] \text{ at } 1130 \text{ cm}^{-1}$$

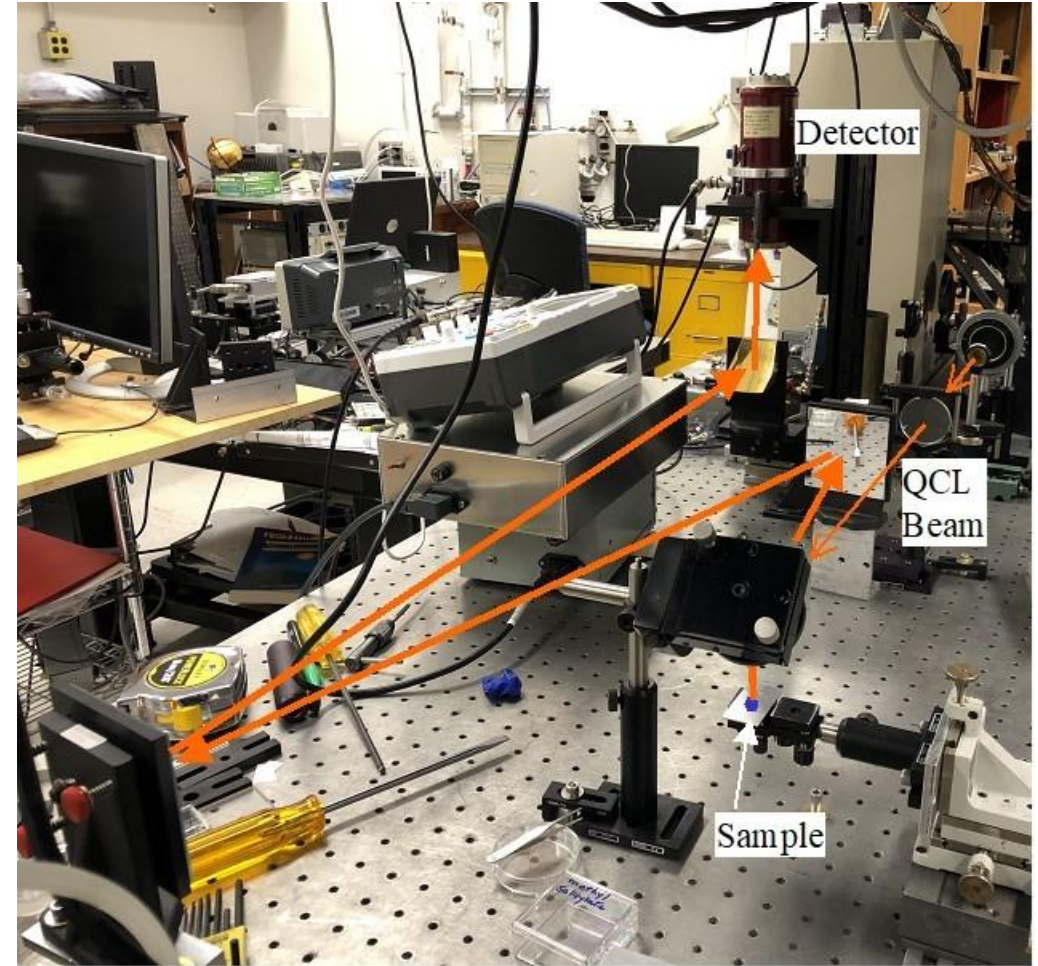
$$t \approx 14 \pm 1 \mu\text{m}$$

$$t \sim \ln R$$

Standoff at 1.8 m for 0.67 μm of Methyl Salicylate



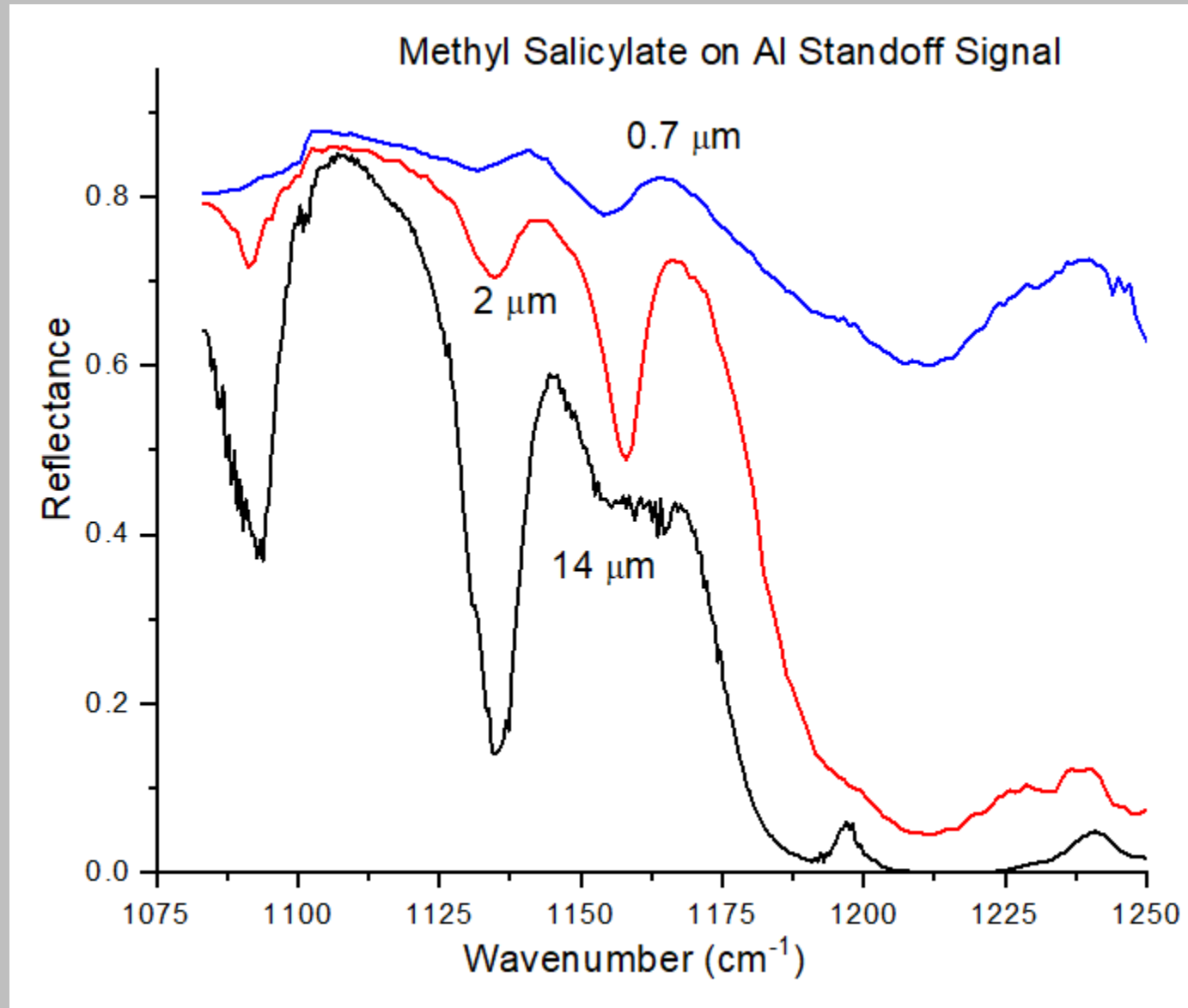
Transmittance for 0.1 mm Methyl Salicylate



Baseline improved with spatial filter. S/N indicates thinner films possible.

Methyl Salicylate on Al: Data for R vs Film Thickness

- Three film thicknesses
- Reflectance declines with thickness
- But is this the case for all substrates?
- Useful to model the effect with thin film optics



High Reflectance Substrates: Reflectance Simulation for Methyl Salicylate Layers

About Substrate Constants

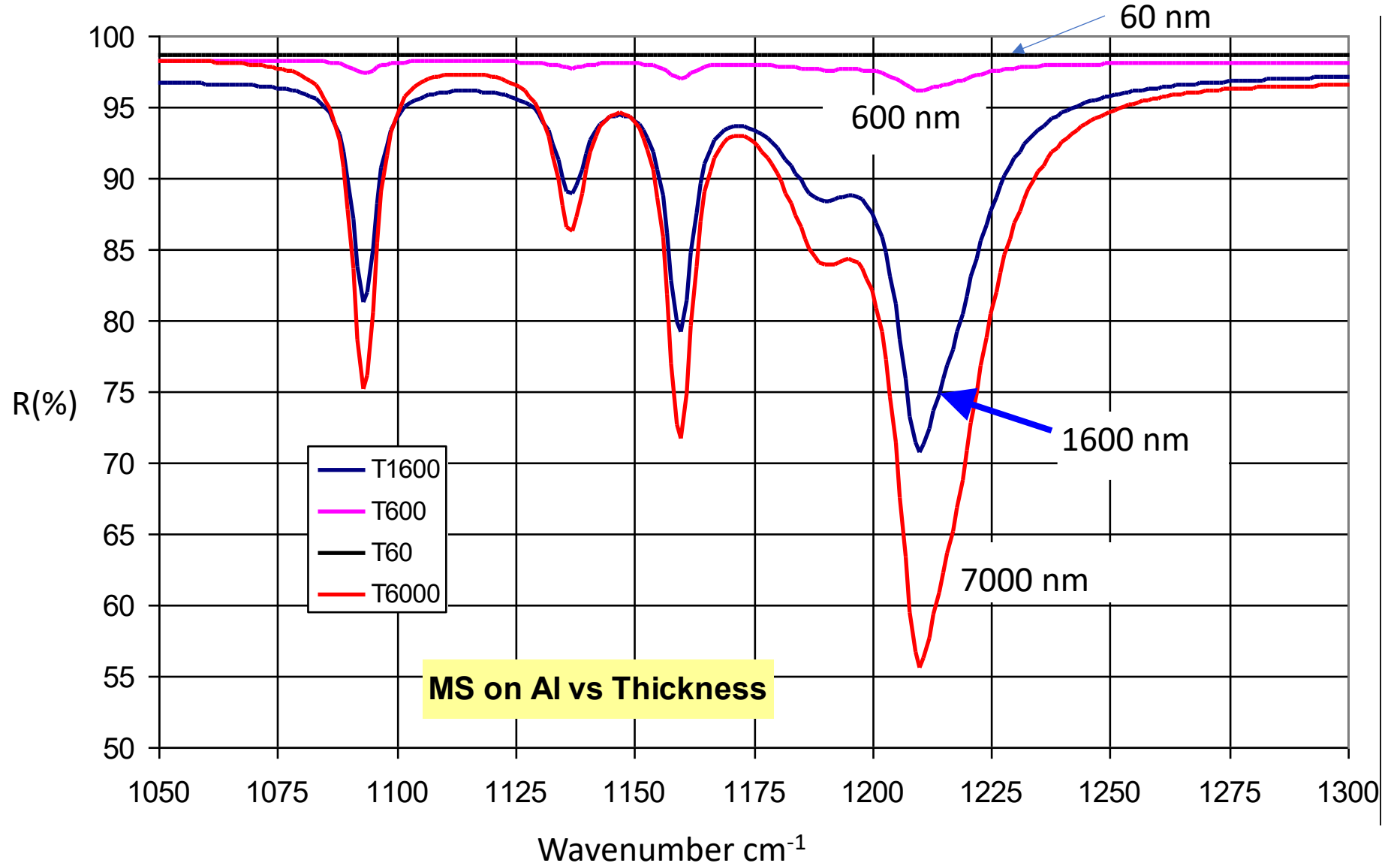
$$R = \frac{(n - 1)^2 + k^2}{(n + 1)^2 + k^2}$$

$$n_{sub} = 8.67$$

$$k_{sub} = 48.6$$

$$R_{sub} = 98.6\%$$

- Calculations done with IGOR using Hansen's formulation
- Reflectance DECREASES from the substrate value
- Now like double pass transmittance
- Absorption depths monotonic with thickness
- Interference noticeable but not large



Low Reflectance Substrates: Reflectance Simulation for Methyl Salicylate Layers

About Substrate Constants

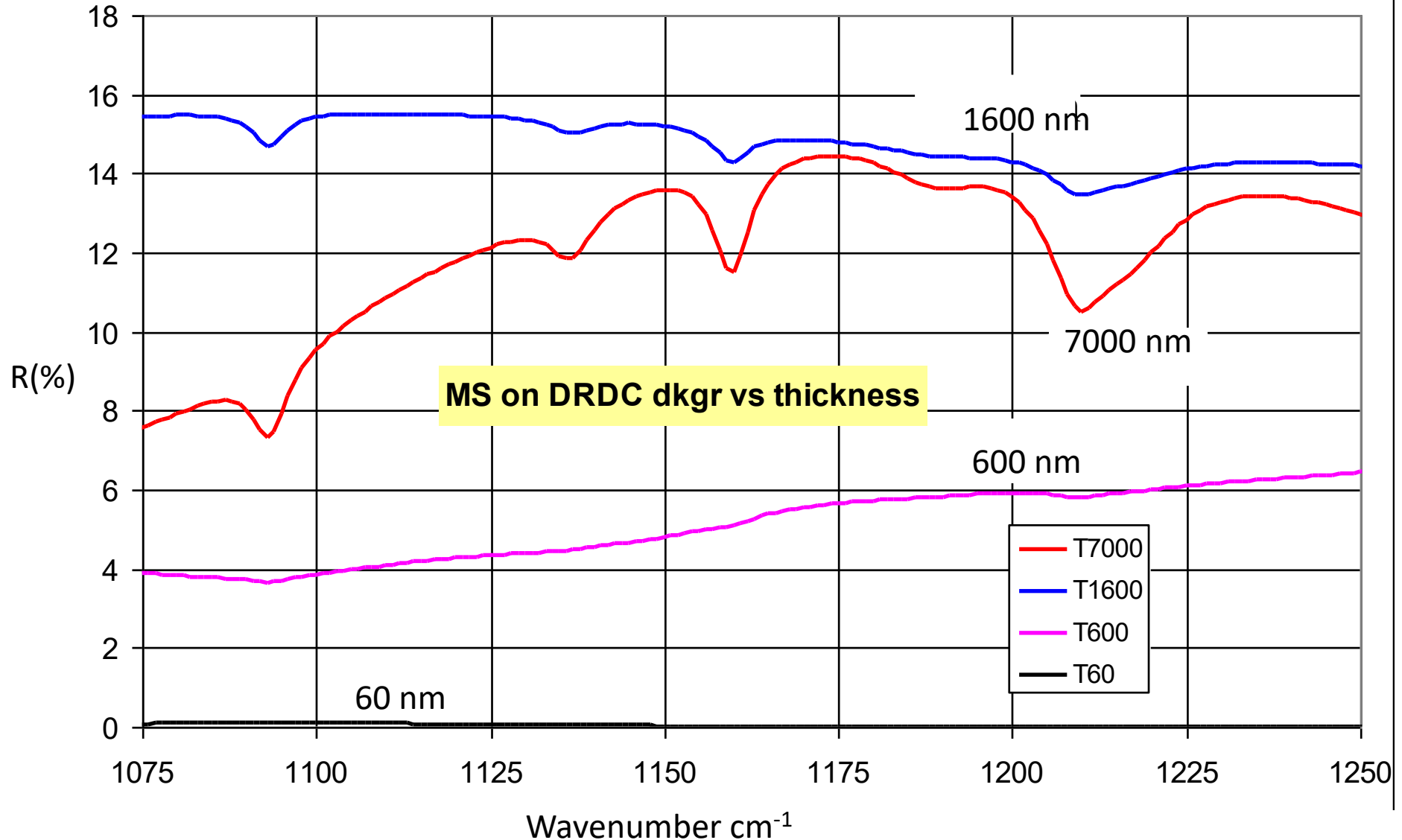
$$R = \frac{(n - 1)^2 + k^2}{(n + 1)^2 + k^2}$$

$$n_{sub} = 1$$

$$k_{sub} = 0.09$$

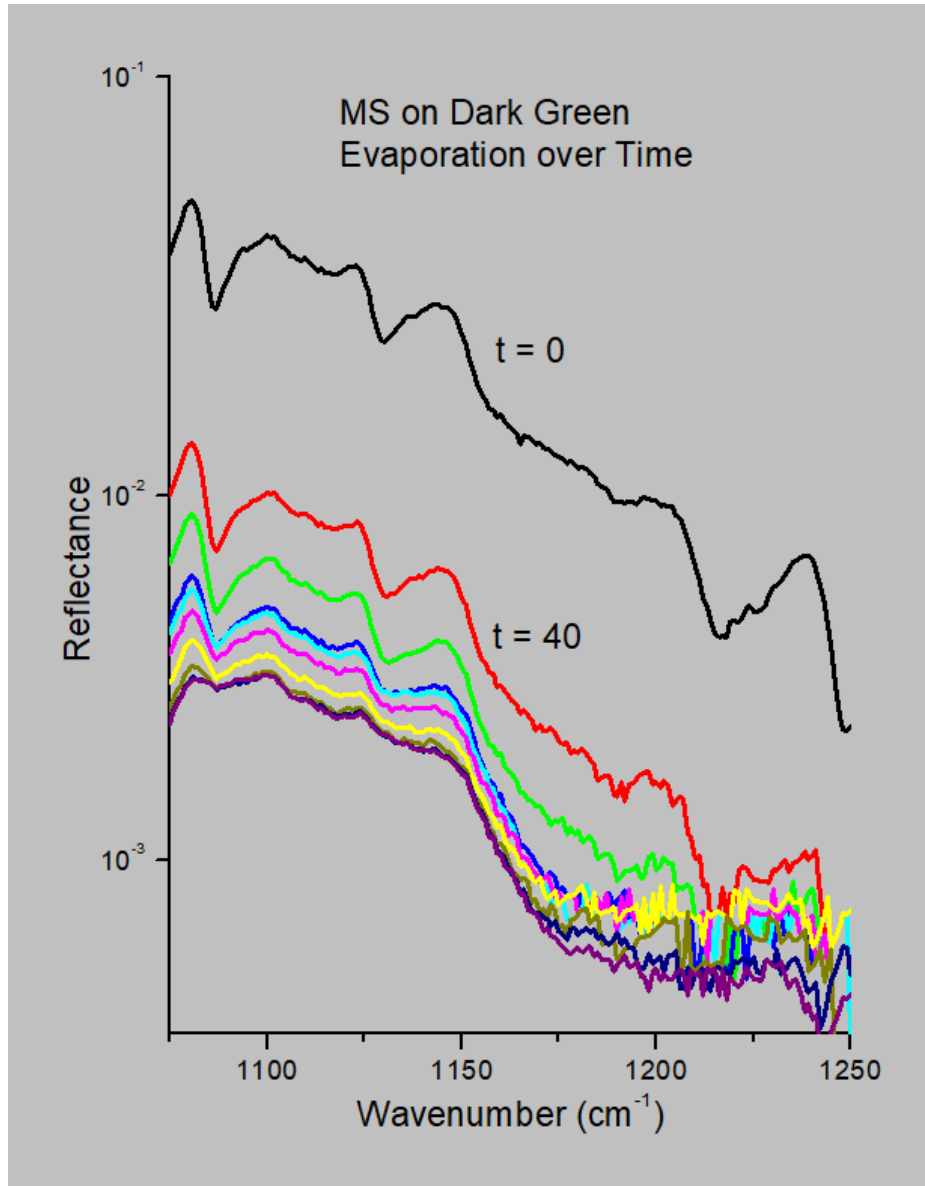
$$R_{sub} = 0.2\%$$

- Reflectance INCREASES from the substrate value
- Now like a free standing film
- Interference effects
- Absorption depths increase with thickness

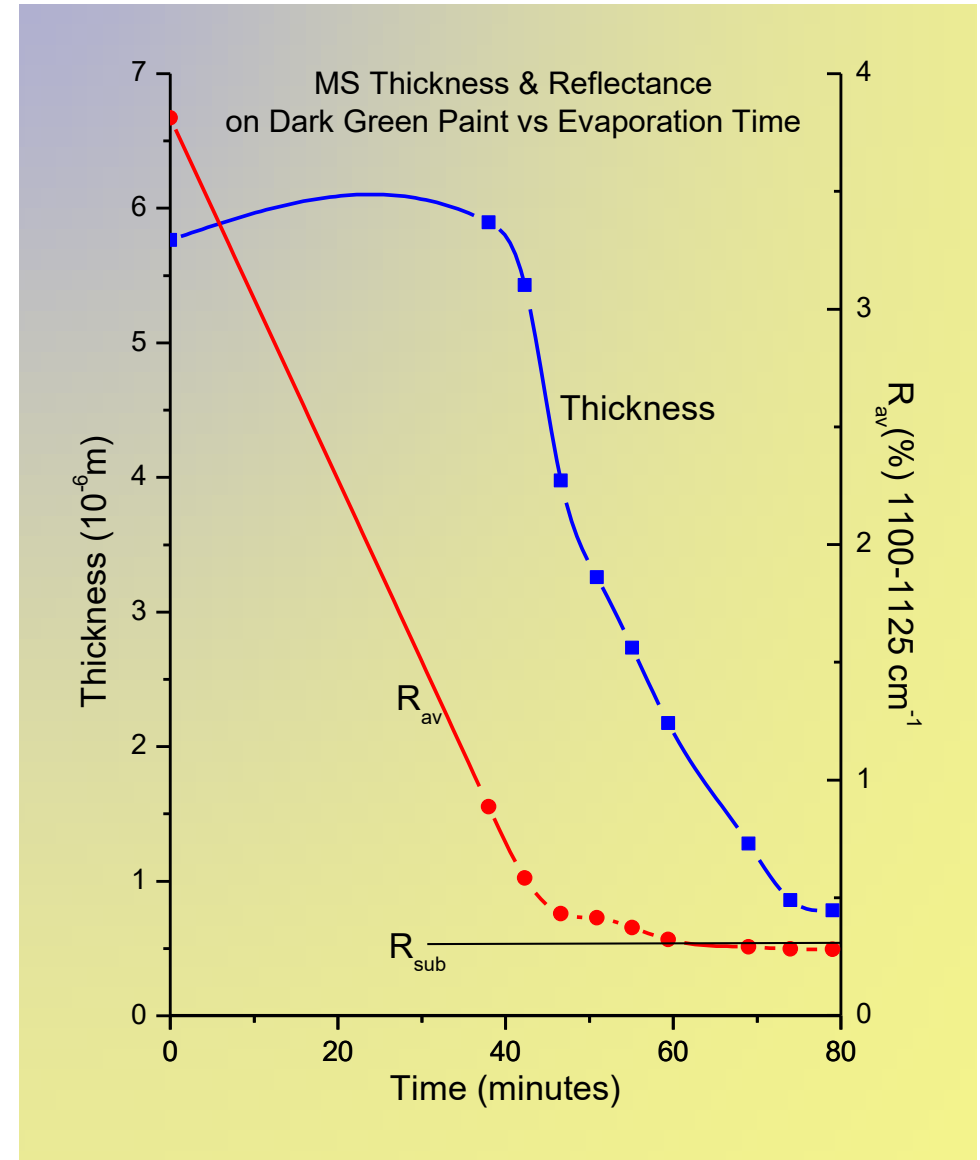


Low R Substrate: Methyl Salicylate Reflectance on Dark Green Paint on Metal

Thickness changes are clear clear on the log scale

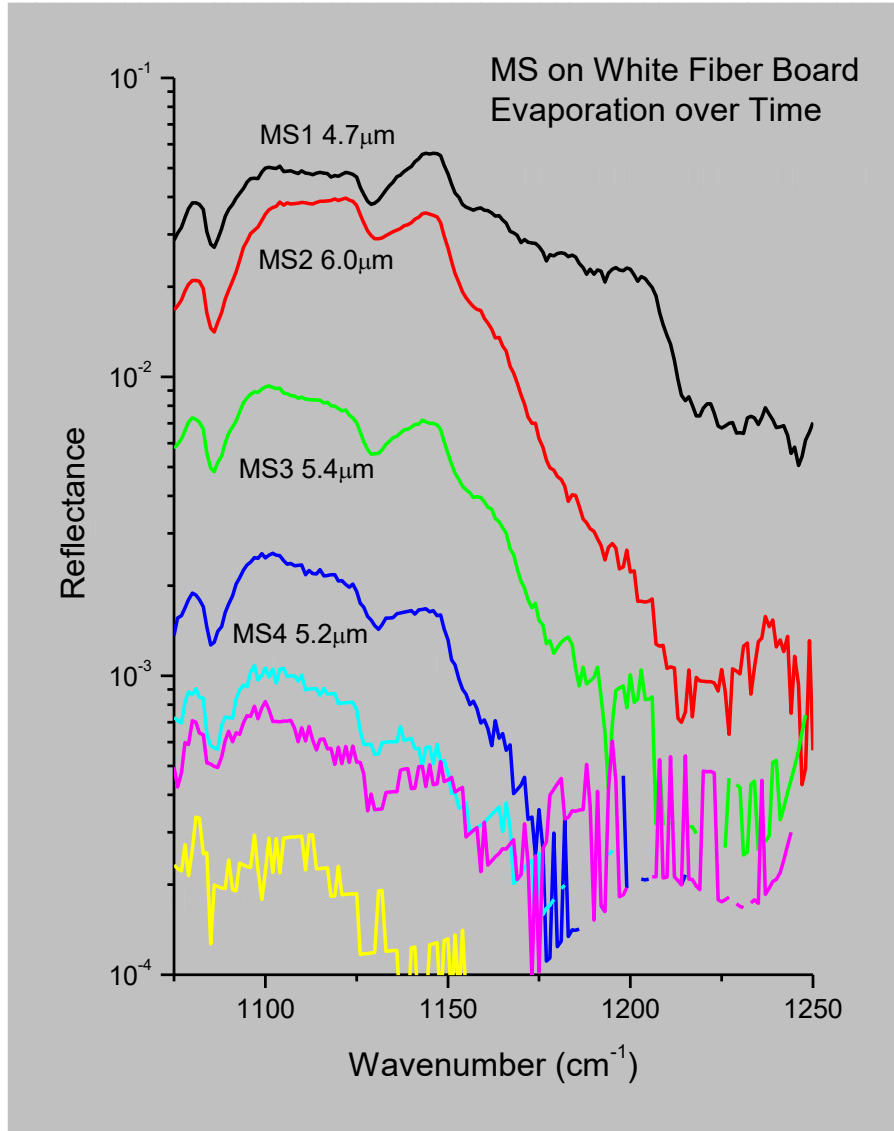


Thickness & coverage decline with time

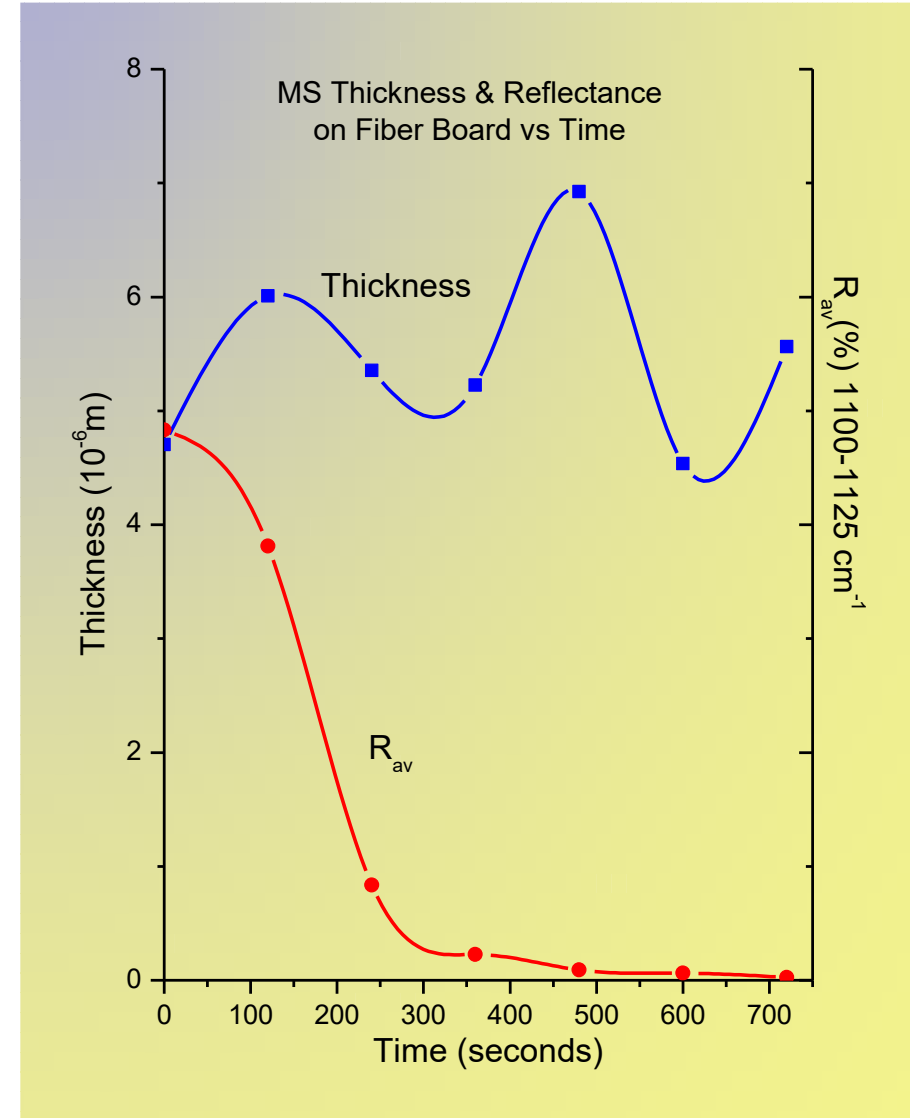


Porous Low R Substrate - Methyl Salicylate Reflectance on White Fiber Board

Constant thickness indicated by constant absorption depth on the log scale



Thickness unchanged with time
Coverage declines rapidly



Summary

Standoff Detection of a Chemical Residue Using Quantum Cascade Lasers

Conclusions

Laser calibration important – spectral & spatial
 Standoff distances in the couple of meter range
 Sub micron layer thickness
 Experiment and calculation, substrate properties

Outlook

New lasers – thinner residues, full spectrum ID
 Larger distances both to laser and detector
 Hyperspectral imaging with FPAs for chemical
 standoff images 800 to 1800 cm^{-1}

